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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/019,087	02/05/1998	HIROYUKI ENOMOTO	TIJ-24816	1640
23494	7590 12/15/2003		EXAM	INER
	TRUMENTS INCORPO	KUNEMUND, ROBERT M		
P O BOX 655474, M/S 3999 DALLAS, TX 75265		ART UNIT	PAPER NUMBER	
,			1765	

DATE MAILED: 12/15/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)
	09/019,087	ENOMOTO ET AL.
Office Action Summary	Examiner	Art Unit
	Robert M Kunemund	1765
The MAILING DATE of this communical	ntion appears on the cover sheet with	the correspondence address
Period for Reply  A SHORTENED STATUTORY PERIOD FOR THE MAILING DATE OF THIS COMMUNIC.  Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this commun. If the period for reply specified above is less than thirty (30) of the period for reply is specified above, the maximum statut.  Failure to reply within the set or extended period for reply will.  Any reply received by the Office later than three months after earned patent term adjustment. See 37 CFR 1.704(b).  Status  1) Responsive to communication(s) filed  2a) This action is FINAL.  2b)  3) Since this application is in condition for closed in accordance with the practice.  Disposition of Claims  4) Claim(s) 1-10 is/are pending in the application is in condition for closed in accordance with the practice.  5) Claim(s) is/are allowed.  6) Claim(s) 1-10 is/are rejected.	ATION. 37 CFR 1.136(a). In no event, however, may a replication.  Jays, a reply within the statutory minimum of thirty (3 ory period will apply and will expire SIX (6) MONTH, by statute, cause the application to become ABAN the mailing date of this communication, even if time on 29 January 2003.  This action is non-final.  T allowance except for formal matter under Ex parte Quayle, 1935 C.D. 1	y be timely filed 30) days will be considered timely. IS from the mailing date of this communication. IDONED (35 U.S.C. § 133). a ely filed, may reduce any  s, prosecution as to the merits is
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction.  Application Papers  9) The specification is objected to by the latest to the specification of	Examiner. a)☐ accepted or b)☐ objected to by	
Replacement drawing sheet(s) including the same of the		•
Priority under 35 U.S.C. §§ 119 and 120		
12) Acknowledgment is made of a claim for a) All b) Some * c) None of:  1. Certified copies of the priority do 2. Certified copies of the priority do 3. Copies of the certified copies of application from the Internationa * See the attached detailed Office action 13) Acknowledgment is made of a claim for since a specific reference was included in 37 CFR 1.78.  a) The translation of the foreign language 14) Acknowledgment is made of a claim for reference was included in the first senter	ocuments have been received. Documents have been received in Application the priority documents have been real Bureau (PCT Rule 17.2(a)). The for a list of the certified copies not redomestic priority under 35 U.S.C. § In the first sentence of the specification has been domestic priority under 35 U.S.C. § Some stic priority under 35 U.S.C. § Some stick priority under 35 U.S.C.	polication No eceived in this National Stage eceived. 119(e) (to a provisional application) ion or in an Application Data Sheet. en received. § 120 and/or 121 since a specific
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO 3) Information Disclosure Statement(s) (PTO-1449) Paper J.S. Patent and Trademark Office	0-948) 5) Notice of Info er No(s) 6) Other:	ormary (PTO-413) Paper No(s)  ormal Patent Application (PTO-152) .
PTOL-326 (Rev. 11-03)	Office Action Summary	Part of Paper No. 32



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In view of the new grounds of rejection PROSECUTION IS HEREBY REOPENED.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
  - (2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or other evidence are permitted. See 37 CFR 1.193(b)(2).

## **DETAILED ACTION**

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to



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consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1 to 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Harai in view of Horioka et al.

The Harai reference teaches a method of making a semiconductor. On a substrate, a first insulating film is formed and a mask is placed on top. A resist film is formed on the mask so that patterns can be created in the mask. Then etching is preformed to etch through the mask, insulating film and substrate to create a trench. A second mask is deposited on to the structure and into the trench. The masks at the bottom of the trench are removed but not from the sidewalls, note figures. The sole difference between the instant claims and the prior art is the further etching of the trench. However, the Horioka et al reference teaches to further etch the bottom of a trench which as a sidewall mask, note translated abs. It would have been obvious to one of ordinary skill in the art to modify the Harai process by the teachings of the Horioka et al reference to further deepen the trench in order to reduce dielectric breakdown.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Robert M Kunemund whose telephone number is 703-308-1091. The examiner can normally be reached on 8 hours.



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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 703-305-2667. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0651.

**RMK** 

ROBERT KUNEMUND PRIMARY EXAMINER